Spin generation, manipulation, and detection in low-dimensional materials have entered a dynamic new phase. The continued miniaturization of magnetic storage and the integration of magnetic devices into current IC chip present new challenges for materials and device scientists, which require continued innovation in material structures as well as in device and system concepts for spin-dependent transport and magnetism. Recent advances in this field include the magnetoresistance effect, diluted magnetic semiconductors, Hall effect, field-free magnetization switching, improved hard magnetic materials, and the exploration of low-dimensional materials with controlled spin states.

The purpose of this special issue is to shed light on some of the current works being done on novel synthesis methods and the physical phenomena occurring in nanoscale magnetic materials that will be used in next-generation spintronic devices. Among the submissions, six papers were selected for publication in this special issue. The theoretical paper by H. B. Huang et al. reported the strain-assisted spin transfer torque (STT) induced magnetization switching in CoFeB-based magnetic tunnel junctions by combining phase-field method with micromagnetic simulations. This work indicates a new aspect of free field magnetization switching and compares it to the previously reported methods such as spin orbital torque combined with exchange bias and broken lateral inversion symmetry. G. Yang et al. reported the ultra-sensitive anomalous Hall effect (AHE) in Ta/CoFe/oxide (MgO and HfO₂)/Ta multilayers and discussed the effect of the annealing process on sensitivity. AHE sensitivity as high as 18792 Ω/T in the as-deposited Ta/CoFe/MgO/Ta was obtained. This work gives a new insight that both the selection of the oxide material and the postannealing treatment play an important role in determining the sensitivity of AHE. The microstructure and magnetic properties of NdFeB films through Nd surface diffusion process were investigated by W. Liu et al., showing that the microstructure and magnetic properties of Ta/Nd/NdFeB/Nd/Ta films are strongly dependent on the NdFeB layer thickness.

The other three papers focused on the magnetoresistance effect of the multilayers and nanowire arrays. X. Liu et al. reported linear magnetoresistance in L1₀-FePt/ZnO/Fe multilayers, in which linear response is observed in a large range from +5 kOe to −5 kOe. This type of linear magnetoresistance is significant for high field linear magnetic sensors. L. Xu et al. reported the magnetoresistance properties of black phosphorus (BP) spin-valve devices consisting of thin BP flakes contacted by NiFe ferromagnetic electrodes. The devices show spin-valve effect from room temperature to low temperature with magnetoresistance of 0.57% at 4 K. Highly ordered arrays of Co/Cu multilayered nanowires were investigated by J. Han et al. using porous anodic alumina (PAA) templates. They discussed the effects of repeat period number and the thickness of the copper layer on the magnetic and magnetoresistance. The editors are sure that this group of papers will be a useful reference for future workers seeking further developments of magnetic nanodevices.
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Xiaohong Xu
Jingsheng Chen
Gillian A. Gehring
Xiangshui Miao
Hao Zeng
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